

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

TAKATOSHI NISHIZAWA, ET AL.

: EXAMINER: VO, H.

SERIAL NO: 10/067,901

FILED: FEBRUARY 8, 2002

: GROUP ART UNIT: 1771

FOR: STRETCHED FILM OF VOID-CONTAINING THERMOPLASTIC RESIN AND PROCESS FOR PRODUCING THE

SAME

REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated March 31, 2006, Applicants request the reconsideration of the rejection of Claims 1 and 3-11, for the reasons set forth below:

OK to enter, HV 10/07/06